

Application Data Sheet**Application Information**

Application Type::	Regular
Subject Matter::	Utility
CD-ROM or CD-R:	None
Title::	METHOD FOR FORMING SILICON EPITAXIAL LAYER
Attorney Docket Number::	117904
Total Drawing Sheets::	2
Small Entity::	Yes

Applicant Information

Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Tae Wan
Family Name::	LEE
City of Residence::	Seoul
Country of Residence::	Rep. of Korea

Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Kyu Jin
Family Name::	CHOI
City of Residence::	Kyunggi-do
Country of Residence::	Rep. of Korea

Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Jung Hoon
Family Name::	SUN
City of Residence::	Kyunggi-do

Country of Residence::	Rep. of Korea
Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Sung Jin
Family Name::	WHOANG
City of Residence::	Kyunggi-do
Country of Residence::	Rep. of Korea
Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Bok Won
Family Name::	CHO
City of Residence::	Kyunggi-do
Country of Residence::	Rep. of Korea

Correspondence Information

Correspondence Customer Number:: 25944

Foreign Priority Information			
Country::	Application Number::	Filing Date::	Priority Claimed::
Korea	2002-75765	12/02/2002	Yes
Assignee Information			
Assignee Name::		JUSUNG ENGINEERING CO., LTD.	
Street of mailing address::		49 NEUNGPYEONG-RI, OPO-MYEON	
City of mailing address::		KWANGJU-GUN	
State or Province of mailing address::		KYUNGGI-DO	
Country of mailing address::		REP. OF KOREA	
Postal or Zip Code of mailing address::		464-890	